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#### Abstract

$F$ ield em ission form ulae, current\{voltage characteristics and energy distribution of em itted electrons, are derived analytically for a nonplanar (hyperboloidal) $m$ etallic em itter $m$ odel. The traditionalFow ler\{N ordheim form ulae, which are derived from a planar em itterm odel, are m odi ed, and the assum ption of the planar em itter in the $\mathrm{F}\{\mathrm{N} \mathrm{m}$ odel is reconsidered. O ur analytical calculation also reveals the backgrounds of the previous num erical discussion by He et al on the eect of the geom etry of em itter on eld em ission. The new form ulae contain a param eter which characterizes the sharpness of the hyperboloidal em itter, and experim ental data of eld em issions from clean tungsten em itters and nanotip em itters are analyzed by $m$ aking use of this feature.


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## I. IN TRODUCTION

The Fow ler\{N ordheim $(F\{N)$ theory $m$ ost im portant theories of electron eld em ission. It describes experim ents, i.e., Clurrent\{voltage characteristics of eld em ission current $n_{12}^{2} \sqrt{23}$ and energy distribution of eld em itted electrons, ${ }^{41}$ quite well. It should be noted, how ever, that the surfapa of em itter is assum ed
 ters are not planar literally, and the fam ous $F$ \{ $N$ form ula $\mathrm{I}=\mathrm{V}^{2} / \exp (\mathrm{A}=\mathrm{V})$, for exam $p l e$, is derived under this assum ption.

This assum ption $m$ ay be considered to be justi ed since the em ission area on the surface ofem itter $m$ ay be lim ited to a so sm allregion at the apex of the em itter that the area can be regarded as planar. T here is how ever no rigorous veri cation of this expectation. Furthem ore, em itters are becoom ing shapper and sharper now adays, e.g., nanotip ${ }^{1514} 16$ em itter m odel is inappropriate. It is hence worthw hile to see how the eld em ission form ulae are $m$ odi ed when the (three dim ensional) geom etry ofem itter is taken into account.

Attempts to incorporate geom etrical e ects into the $F\left\{\mathrm{~N}_{\mathrm{m}}\right.$, the ,
 charge potentials exactly for the tips shaped. fike cone, hyperboloid, paraboloid, and sphere on cone $i_{1}^{181}$ and discussed the e ect of the geom etry of the em itters on eld em ission't' They num erically obtained (i) eld em ission currents from the apex of those em Itters and (ii) (normal ) energy distributions of em itted electrons, and they concluded that (i) the current\{voltage characteristics for the nonplanar (and rather shanp) em itters can be $t$ ted with the relationship $I=V^{2} / \exp \left(A=V \quad B=V^{2}\right)$, which is di erent from the one by the $\mathrm{F}\left\{\mathrm{N}\right.$ m odel, $\mathrm{I}=\mathrm{V}^{2}$ / $\exp (A=V)$, and that (ii) the energy distributions for the nonplanar $m$ odels are $m u c h ~ w i d e r ~ t h a n ~ t h a t ~ f o r ~ t h e ~ F ~\{~ N ~$ planarm odel.

In this article, we successfully derive analytical form ulae for current\{voltage characteristics and energy distribution for a hyperbobidal em itter $m$ odel (although the im age charge e ect is neglected). Even though our form ulae are valid only for conventionalem itters whose tip radii of curvature are of the order of 100 nm , they still re ect the geom etry of the em itter and the traditional F \{N form ulae are m odi ed. Furtherm ore, our analytical calculation enables us to discuss the assum ption of the planar em 计ter in the $F$ \{ N m odel, and also helps us understand the backgrounds of the above-m entioned num erical discussion by He et al. A nd at the nal part of this article, experim entaldata of eld em issions from nanotip em ittersí are analyzed by making use of a param eter, which characterizes the sharpness of the hyperboloidal em itter and never com es in the ordinary $\mathrm{F}\{\mathrm{N}$ theory based on the planar em itter $m$ odel.

## II. HYPERBOLOIDALEM ITTER MODEL

O ur m odel is ilhustrated in $F$ ig. $1 \overline{111}$. It is com posed of a hyperboloidalm etallic em itter and a planar collector. The work function of the em itter, , is assum ed to be


F IG .1: A m odelcom posed ofa hyperboloidalm etallic em itter and a planar collector. A typical set of param eters in an actual experim ent ${ }^{6 / 6}$ is $L \quad 5 \mathrm{~cm}, V_{0} \quad 3 \mathrm{kV}$, and $\quad 4: 4 \mathrm{eV}$ (tungsten). The work function of the em itter, , is assum ed to be uniform.
uniform on the surface of the em itter.
In- is -implicitly assum ed in the ordinary $F\{N$ the-
 em itter, from which electrons are em itted, is lim ited to a very sm all region at the apex of the em itter and can be regarded as planar. T he surface of the em itter is thus m odelled by a plane, and tunnelling ofelectrons through a one-dim ensional potentialbarrier at the surface is discussed. In this article, on the contrary, we duly take the shape of the em itter into account and proceed w ithout such an assum ption. The size of the em ission area is also what is to be clari ed as a result of the follow ing calculation.

We work in an orthogonal curvilinear coordinate system, i.e., an ellipsoidal coordinate system (u;v;') $\mathbb{E}$ ig. in (a)]. It is related to the cylindrical coordinate system ( ; ' ; z) by

$$
\begin{align*}
(z & =a \cos u \cosh v ;  \tag{2.1}\\
& =a \sin u \sinh v ;
\end{align*}
$$

or

$$
\begin{equation*}
z+i=a \cos (u+i v) ; \tag{22}
\end{equation*}
$$

where the ranges of the coordinates are $0 \quad u \quad$ u $0 \mathrm{v}<1$, and $0,<2 \mathbb{E}$ ig $\mathrm{v}=$ const. is an ellipsoid, and a surface $\mathrm{u}=$ const. is a hyperboloid. The expression (2-2) w ith an analytic function show $s$ that this $m$ apping is a conform al one and the ellipsoidalcoordinate system in Fig. one.

W e attach the ellipsoidalcoordinate system in $F$ ig ${ }^{2}$, 1 (a) to the m odel in Fig. '11' such that the plane $u==2$ is on the collector and a hyperboloid $u=u_{0}$ is on the surface of the em itter. The param eters $a$ and $u_{0}$ are related to the distance from the apex of the em itter to the collector, L, by

$$
\begin{equation*}
\mathrm{L}=\mathrm{a} \cos u_{0} \tag{2.3}
\end{equation*}
$$

and to the radius of curvature of the tip, $R$, by

$$
\begin{equation*}
\mathrm{R}=\mathrm{a} \frac{\sin ^{2} u_{0}}{\cos u_{0}}=\mathrm{L} \tan ^{2} u_{0}: \tag{2.4}
\end{equation*}
$$



FIG.2: A n ellipsoidal coordinate system (u;v;'). This is a 3-dim. orthogonal curvilinear coordinate system. T he whole plane in (a) is $m$ apped onto the region 0 u in (b)


TABLE I: R adius of curvature $R$ vs $u_{0}$ for $L=5 \mathrm{~cm}$.

| $\mathrm{u}_{0}$ | 0.0010 | 0.0015 | 0.0020 |
| :---: | :---: | :---: | :---: |
| $\mathrm{R}(\mathrm{nm})$ | 50 | 110 | 200 |

$u_{0}$ is the param eter which characterizes the sharpness of the em itter. Typical values of it are show in Table It It should be noted here that this param eter is not contained in the ordinary $F$ \{ $N$ theory since the $F$ \{ $N$ theory is based on the planar em itter m odel.

In this coordinate system, the Laplacian $r^{2}$ is given by

$$
\begin{align*}
r^{2}= & \frac{1}{\bar{g}} \frac{\varrho}{\varrho u} a \sin u \sinh v \frac{@}{@ u}+\frac{1}{P} \frac{\varrho}{g} \frac{\varrho}{@} a \sin u \sinh v \frac{\varrho}{@ v} \\
& +\frac{1}{a^{2} \sin ^{2} u \sinh ^{2} v} \frac{\varrho^{2}}{\varrho^{2}} \tag{2.5}
\end{align*}
$$

$w$ th ${ }^{\mathrm{P}} \bar{g}=a^{3}\left(\sin ^{2} u \cosh ^{2} v+\cos ^{2} u \sinh ^{2} v\right) \sin u \sinh v$, and the Laplace equation $r^{2} V=0 \mathrm{w}$ th the boundary conditions $V=0$ on the surface of the em itter and $\mathrm{V}=\mathrm{V}_{0}$ on the collector plane, where $\mathrm{V}_{0}(>0)$ is the applied voltage, is reduced to

$$
\begin{array}{ll}
\frac{d}{d u} \sin u \frac{d}{d u} v(u)=0 ; & \left(u_{0}\right)=0 ;  \tag{2.6}\\
& v(=2)=V_{0}:
\end{array}
$$

It is then easy to obtain the electric potential V (u) betw een the em ilter and the collector: It reads

$$
\begin{equation*}
V(u)=V_{0} \quad 1 \quad \frac{\ln \cot (u=2)}{\ln \cot \left(u_{0}=2\right)}: \tag{2.7}
\end{equation*}
$$

An equipotential surface is a hyperboloid $u=$ const., and an electric line of force is a curve along an ellipse $\mathrm{v},{ }^{\prime}=$ const. T he potential energy of an electron in the electric eld,


FIG. 3: Potential energy of an electron, $U$ in Eq. (2. w ith (2.7), on the $z$-axis for $L \quad 5 \mathrm{~cm}, \mathrm{R} \quad 100 \mathrm{~nm}$, and $\mathrm{V}_{0} \quad \overline{\mathrm{kVV}}$. . The U -axis is drawn at the apex of the em itter. $T$ he potentialnear the apex in (a) is en larged in (b). (a) $D$ ue to the sharpness of the em itter, a strong eld is realized near the apex of the em itter, and (b) the thickness of the tunnelling barrier is of the order of 1 nm .
where e e $(<0)$ is the charge of the electron, is draw $n$ in $F$ ig. charge potential.
III. GENERALIZATION OF THE F\{N THEORY FOR THE HYPERBOLODALEM ITTER MODEL

Generalizing the $F$ \{ $N$ theory eld em ission current I for the hyperboloidal em itter m odel by the equation

E and W are the \total" and \nom al" energies of an electropn, respectively ${ }^{\frac{1}{4}} \mathrm{~N}$ ( $\mathrm{W} ; \mathrm{E} ; \mathrm{v}$ ) is called supply function ${ }^{1 / 4}$ and $N(W ; E ; V) d W d E d v d^{\prime}$ gives the num ber of electrons incident on the area $d v d^{\prime}$ around the position ( $\mathrm{v} \boldsymbol{\prime}^{\prime}$ ) on the face of the potentialbarrier $u=u_{0}$ per unit tim e, with the total energy within the range E to $E+d E$ and the norm al energy $w$ thin the range $W$ to $W+d W . D(W ; v)$ is the probability of an electron penetrating the potential barrier at $\left(\mathrm{v} \boldsymbol{i}^{\prime}\right)$ w ith the nom al energy $W$. We obtain the em ission current I by sum $m$ ing up the num ber of em itted electrons per unit tim $e$, N (W ; E ; v)D (W ; v) dW dE dv d', for allpossible energies (W);E) and for all positions ( $v ;^{\prime}$ ) on the surface of the em itter, i.e., by Eq. (3.1) .

It should be noted in this form ulation that the radius of curvature of the em itter is assum ed to be $m$ uch larger than the de B roglie w ave length of an electron ( $0: 1 \mathrm{~nm}$ ) since electrons are treated as localized ob jects. (For conventional em itters, the radii of curvature are of the order of 100 nm .) U nder this assum ption, the surface of the potential barrier $u=u_{0}$ seem s planar to an electron, and the other surface of the barrier (the end of the tunnelling region) $u=u_{T}$, which is separated from the surface $u=u_{0}$ only by the distance of the order of 1 nm , also seem splanar and parallelto the surface $u=u_{0}$. This observation leads us to the follow ing explicit form ulae for $\mathrm{D}(\mathrm{W} ; \mathrm{V})$ and N ( $\mathrm{W} ; \mathrm{E} ; \mathrm{v}$ ).

For the barrier penetration probability $D(W ; v)$, let us consider the Schrodinger equation

$$
\begin{equation*}
\frac{h^{2}}{2 m} r^{2}+U(u) \quad\left(u ; v ;^{\prime}\right)=E \quad\left(u ; v \boldsymbol{i}^{\prime}\right) \tag{32}
\end{equation*}
$$

w th the Laplacian $r^{2}$ given in Eq. (2.5) and the potential barrier $U(u)$ in Eq. (2.8) w ith (2,71). (m is the $m$ ass of an electron.) D ecom posing the wave function as (u;v;') $=e^{i(u ; v)=h} e^{i p},^{\prime}=h$, where (u;v) $=$ ${ }_{R}(u ; v)+i_{I}(u ; v)$ is a com plex-valued function and $p$, a real constant (angular $m$ om entum around the $z$-axis), the Schrodinger equation $\left.(3)^{2} \underset{\sim}{2}\right)$ is reduced in the W K B


$$
\begin{align*}
& \frac{a \sin u \sinh v}{P \bar{g}} \frac{@}{@ u}^{2}+\frac{@}{@ v}^{2}+\frac{p_{1}^{2}}{a^{2} \sin ^{2} u \sinh ^{2} v} \\
& =2 m \mathbb{E} \quad U(u)]: \tag{3.3}
\end{align*}
$$

It is expected in the tunnelling region that there does not exist oscillating-w ave $m$ ode in the u-direction nor dam ping-w ave $m$ ode in the $v$-direction (along an equipotential curve). It $m$ ight be hence reasonable to assum e that

$$
\begin{equation*}
\frac{@ R}{@ u}, 0 ; \frac{@ I}{@ v}, 0 ; \tag{3.4a}
\end{equation*}
$$

and

$$
\begin{equation*}
\frac{a \sin u \sinh v}{P \bar{g}} \frac{@}{@}^{2}, 2 m[\mathbb{U}(u) \quad W] ; \tag{3.4b}
\end{equation*}
$$

$\frac{a \sin u \sinh v}{P_{\bar{g}}} \frac{@_{R}}{@ v}{ }^{2}+\frac{p_{r}^{2}}{a^{2} \sin ^{2} u \sinh ^{2} v}, 2 m(E \quad W) ;$
where $W$ ( $\mathrm{E}<\mathrm{U})$ is regarded as the nom al energy.


$$
\begin{align*}
& I(u ; v)^{\prime} \quad d s \frac{p}{2 m \llbracket(u) \quad W]} ;  \tag{3.5a}\\
& R(u ; v)^{\prime} \quad d^{\prime} \quad 2 m(E \quad W) \frac{p_{r}^{2}}{a^{2} \sin ^{2} u \sinh ^{2} v} \tag{3.5b}
\end{align*}
$$

ds and d' are the length elem ents along the curve v , ' = const. and the curve $u, '=$ const., respectively, given by ${ }^{131}=$

$$
\begin{align*}
& d s=a^{p} \overline{\sin ^{2} u \cosh ^{2} v+\cos ^{2} u \sinh ^{2} v} d u  \tag{3.6a}\\
& d^{\prime}=a^{p} \overline{\sin ^{2} u \cosh ^{2} v+\cos ^{2} u \sinh ^{2} v} d v: \tag{3.6b}
\end{align*}
$$

O ne can con $m$ the consistency of the solution (3.5) w ith Eq. ( 3.4$)^{\prime}$ ') under the situation of sm all curvature and short tunnelling length $m$ entioned in the previous paragraph. The barrier penetration probability $D(W) ; v)$ for an electron at $\left(v ;^{\prime}\right)$ is thus given by

$$
\begin{equation*}
\mathrm{D}(\mathrm{~W} ; \mathrm{V})=\mathrm{e}^{2 \mathrm{~S}(\mathrm{~W} ; \mathrm{v})=\mathrm{h}} ; \tag{3.7a}
\end{equation*}
$$

$N$ ote that $u_{T}$ is determ ined by the equation $U\left(u_{T}\right) \quad W=$ 0 .

The supply function at each point on the surface of the potential barrier is given by the same formula as that for the planar em itter $m$ odel, which is derived in Ref. 'AL', since the surface of the barrier seem s planar to electrons around that point. H enœ the supply function N (W ; E ; v) dv $d^{\prime}$ reads

$$
\begin{equation*}
N(W ; E ; v) d v d^{\prime}=\frac{m}{2^{2} h^{3}} \frac{1}{e^{(E+)=k_{B} T}+1} d^{2} ; \tag{3.8}
\end{equation*}
$$

where $d^{2}$ is the arealelem ent on the surface of the em itter de ned by

$$
\begin{equation*}
d^{2}=d^{\prime} d^{\prime} w \text { th } u=u_{0}: \tag{3.9}
\end{equation*}
$$


$W$ ith these com ponents together, we rst caleplate the (total) energy distribution of em itted electron $s^{\Phi_{1}}$

$$
\begin{equation*}
P(E)=d_{0}^{Z} d_{0}^{Z} \int_{1}^{Z E} d v W^{Z} d W(W ; E) D(W ; v) ; \tag{3.10}
\end{equation*}
$$

and then obtain the em ission current I by

$$
I=e^{Z} d E P(E):
$$

Before going on any further, let us sum $m$ arize the differences betw een our form ulation and that of He et al. in Ref. 19.1 . (i) W e neglect the im age charge potential while He et al calculated it exactly ${ }^{81}$ (ii) W e count the electrons em itted from all over the surface of the em itter through the v-integration in Eq. (3, (1) while He et al assum ed, as in the ordinary $F$ \{ $N$ theory, that the em ission area on the surface of the em itter is sm all enough and is regarded as a plane. T hese tw o points w ill be addressed in the follow ing.
A. Energy distribution P (E)

U nfortunately, it is not possible to carry out the integrations exactly, but a few reasonable approxim ationsen-

$$
\begin{aligned}
& d s^{\prime} a \sin u_{0} \quad 1+\left(u \quad u_{b}\right) \cot u_{0}+\frac{1}{2} 1 \quad(u \quad u) \cot u_{0} \quad \frac{v}{\sin u_{0}}{ }^{2} \\
& \frac{1}{8} \quad 1 \quad \frac{4}{3} \sin ^{2} u_{0}+\frac{4}{3}(u
\end{aligned}
$$

and neglected $O\left(\left(u_{T} \ldots u_{b}\right) \cot u_{0}\right)$ term $s$. The term ( $\left.\mathrm{v}=\sin \mathrm{u}_{0}\right)^{4}$ in Eq. (3.13) is negligible in the form $u$ -
able usto achieve analyticalform ulae. The rst one isthe linear approxim ation of the potential $V(u)$ in Eq. ( 2.7 i. $)$, which one $m$ ay realize from $F$ ig.

$$
\begin{equation*}
V(u)^{\prime} \frac{V_{0}}{\sin u_{0} \ln \cot \left(u_{0}=2\right)}\left(u \quad u_{b}\right): \tag{3.12}
\end{equation*}
$$

$T$ his is valid if ( $\left.u_{T} \quad u_{0}\right) \operatorname{cotu}_{0}$ ' ( $\left.W=e V_{0}\right) \cos _{0}$ In cot $\left(u_{0}=2\right) \quad 1$, which is satis ed in conventional experim ents: ( $\left.u_{T} \quad u_{0}\right)$ cotu $u_{0} \quad 10^{2}$ for $R \quad 100 \mathrm{~nm}$, $\mathrm{L} \quad 5 \mathrm{~cm}, \mathrm{~V}_{0} \quad 3 \mathrm{kV}$, and $\mathrm{W} \quad 4: 4 \mathrm{eV}$. (In this section, we w ill often dem onstrate the validity of approxim ations w ith this set of param eters. W e hereafter call it \case I" for short. O f course, this is not the only situation to which our form ulae are applicable.) In this regim $e$, one can evaluate the action $S$ ( $W$; $v$ ), de ned in Eq. (3.7d) , for $v=\sin u_{0} \quad 1$ (near the apex of the em itter) as

$$
\begin{align*}
& S(\mathbb{W} ; v)^{\prime}{\frac{2 m e V_{0}}{\sin u_{0} \ln \cot \left(u_{0}=2\right)}}_{u_{0}}^{z_{T}} d s{ }^{p} \overline{u_{T} \quad u} \\
& \text {, } S_{0}(\mathbb{W}) 1+\frac{1}{2} \frac{v}{\sin u_{0}} \\
& \frac{1}{8} 1 \quad \frac{4}{3} \sin ^{2} u_{0} \quad \frac{v}{\sin u_{0}}{ }^{4}+\quad ; \tag{3.13}
\end{align*}
$$

$w$ here the factor $S_{0}(\mathbb{W})=S(W ; 0)$ is the action along the z -axis given by

$$
\begin{equation*}
S_{0}(W), \frac{2 a^{\mathrm{p}} \overline{2 \mathrm{~m}(\mathrm{WP}}}{3 \mathrm{eV} V_{0}} \sin ^{2} u_{0} \ln \cot \left(u_{0}=2\right): \tag{3.14}
\end{equation*}
$$

In this evaluation, we have expanded the length elem ent
In this evaluation, we have expanded the length elen
ds given in Eq. ( $\left(\frac{\left.6 a^{\prime}\right)}{}\right)$ around $u=u_{0}$ and $v=0$ as
region where the barrier penetration probability $D$ ( W ; v ) in Eq. (3.7 ) is not zero], i.e., $8 \mathrm{~S}_{\mathrm{o}_{2}}(\mathrm{~W})=\mathrm{h} \quad 1$. N ote here that the W K B approxim ation ( $\overline{3} . \overline{7})$ is a sem i-classicalapproxim ation and is valid for large $S(W ; v)=h$. Typical value of $S_{0}(W)=h$ is $S_{0}(\ldots)=h \quad 7: 6$ in the case I. The arealelem ent $d^{2}$ in Eq. (3.9) is also approxim ated by

$$
\begin{equation*}
d^{2} \quad, a^{2} v \sin ^{2} u_{0} d v d^{\prime} \tag{3.16}
\end{equation*}
$$

for $v=\sin u_{0} \quad 1$, and the integration one should carry out is now

$$
\begin{align*}
& P(E) \quad \frac{m a^{2} \sin ^{2} u_{0}}{h^{3}} \frac{1}{\left.e^{(E+}\right)=k_{B} T}+1 \\
& \quad \mathrm{Z} \quad \mathrm{Z}^{\mathrm{E}}  \tag{3.17}\\
& \quad \mathrm{dW} \quad d v v \exp \quad \frac{2}{h} S_{0}(W) \quad 1+\frac{1}{2} \frac{v}{\sin u_{0}}
\end{align*}
$$

where the action $S_{0}(\mathbb{W})$ is given in Eq. ( $\left.\overline{1} \overline{1} \overline{4}\right)$. We thus reach the energy distribution form ula for the hyperboloidal em itter $m$ odel:

$$
\begin{align*}
& P(E)=\frac{2 m R^{2}}{3 h^{3}(L+R)} \frac{1}{e^{(E+)=k_{B} T}+1}  \tag{3.18}\\
& \frac{1}{\left(2 S_{0}=h\right)^{2=3}} \quad\left(\quad 1=3 ; 2 S_{0}(E)=h\right) ;
\end{align*}
$$

where

$$
\begin{equation*}
S_{0}=S_{0}(\quad)=\frac{2 L^{p} \overline{2 m^{3}}}{3 e V_{0} 0} \tag{3.19}
\end{equation*}
$$

w ith a modi cation factor for eld strength,

$$
\begin{equation*}
0=\frac{\operatorname{cosen}_{0}}{\sin ^{2} u_{0} \ln \cot \left(u_{0}=2\right)} ; \tag{320}
\end{equation*}
$$

which com es from the shanpness of the em itter, and

$$
\begin{equation*}
(z ; p)={ }_{p}^{z} d t t^{z} 1 e^{t} \tag{321}
\end{equation*}
$$

is the incom plete gamm a function. Since $(z ; p)$ has an asym ptotic expansion

$$
\begin{align*}
& (z ; p)=p^{z^{1}} e^{p} \\
& 1+{ }_{n=1}^{X^{1}} \frac{1}{p^{n}}\left(\begin{array}{llll}
z & 1)\left(\begin{array}{ll}
z & 2
\end{array}\right) & \left(\begin{array}{ll}
z & n
\end{array}\right)+\mathbb{N} \times \dot{p} j
\end{array},\right. \tag{322}
\end{align*}
$$

 approxim ated by

$$
\begin{align*}
P(E)^{\prime} & \frac{2 m \mathrm{LR}^{2}}{3 \mathrm{~h}^{3}(\mathrm{~L}+\mathrm{R})} \frac{1}{e^{(\mathrm{E}+)=k_{B} T}+1} \\
& \frac{1}{\left(2 \mathrm{~S}_{0}=\mathrm{h}\right)^{2}} \exp \quad\left(2 \mathrm{~S}_{0}=\mathrm{h}\right) \quad 1 \quad \frac{3}{2} \frac{\mathrm{E}+}{} \tag{323}
\end{align*}
$$

when the action $2 \mathrm{~S}_{0}=\mathrm{h}$ is large. N ote that we had already assum ed $8 \mathrm{~S}_{0}=\mathrm{h} \quad 1$ in Eq. (30.17). N oticing the high energy cut-o by the Ferm i\{D irac distribution and the low energy oneby the exponential factor in the expansion $(\overline{3} \overline{2} \overline{2})$ ), the action $S_{0}(\mathbb{E})$ has been expanded around the Fem i levelE _ $\quad E_{F}=$ _ $\quad$ Eq. $(3$ (2ß). The energy distributions ( $(\overline{3} \overline{1} \overline{1} \overline{-1})$ and $(\overline{3} 2 \overline{3})$ are derived under the conditions

$$
\left(u_{T} \quad u_{b}\right) \cot u_{0}, \frac{L}{R} \frac{3 S_{0}}{e V_{0} \quad}, \frac{P_{0}}{2 \mathrm{P}^{2 m}} 1
$$

(324a)
and

$$
\begin{equation*}
8 \mathrm{~S}_{0}=\mathrm{h} \quad 1 ; \tag{3.24b}
\end{equation*}
$$

nam ely, they are valid for the param eters satisfying

$$
\begin{equation*}
1 \quad 8 \mathrm{~S}_{0}=\mathrm{h} \quad \frac{16 \mathrm{R}^{\mathrm{p}} \overline{2 \mathrm{~m}}}{3 \mathrm{~h}}: \tag{325}
\end{equation*}
$$

The energy distribution $(\overline{3} 2 \overline{2} \overline{3})$ is plotted in $F$ ig. $\overline{4}$. It is clear from the expression ( $\left.(\underline{3}, 1)_{1}\right)$ and $(\underline{3}-2,-1)$ that the



$$
E-E_{F}(\mathrm{eV})
$$

FIG. 4: (a) The energy distributions ( 3 23) for zero and nonzero tem peratures. The radius of curvature of the em itter is $R=110 \mathrm{~nm}$ ( $\mathrm{u}_{0}=0: 0015$ ). The peak of the distribution for zero tem perature is nom alized to unity. (b) The energy distributions (32-1) for di erent radii of curvature. $u_{0}=0: 0018$ for $R=160 \mathrm{~nm}$ and $u_{0}=0: 0012$ for $R=70 \mathrm{~nm}$. Tem perature is $T=300 \mathrm{~K} . \mathrm{T}$ he peak of each distribution is nom alized to unity. O ther param eters forboth gures (a) and (b) are those of the case I.
action $S_{0}$ as well as the tem perature $T$ characterizes the energy distribution $P(E)$. R oughly speaking, the tem perature $T$ determ ines the high energy cut-o of the distribution $\mathbb{E}$ ig. ${ }^{\prime}$ I' (a) ], and the action $S_{0}$ the low energy one $\mathbb{F}$ ig. 'I' (b) ]. For a sharperem itter, the action $S_{0}$ is sm aller [see Eqs. (3.19) and ( $\mathbf{3}_{2}^{2} \mathbf{2 0}^{\prime}$ )], and the energy distribution
 the num erical calculation by He et al in Ref. ${ }_{1} 1.1$. Further$m$ ore, we have an explicit expression for a $m$ easure of the width of the distribution, E :

$$
\begin{equation*}
\mathrm{E}=\frac{\mathrm{k}_{\mathrm{B}} \mathrm{~T}}{\sin \left(3 \mathrm{k}_{\mathrm{B}} \mathrm{TS} \mathrm{~S}_{0}=\mathrm{h}\right)} ; \tag{3.26}
\end{equation*}
$$

which is the deviation of the distribution $P_{1}(E)$ de ned by $E=P \quad \overline{h E^{2} i} \quad h E$ I where $h E^{n} i=\begin{array}{rl}R_{1} & d E \\ R_{1} & E^{n} P(E)= \\ R_{1} & d E P(E) \text {. Rem em ber the integral }\end{array} \quad d x e^{x=d=}$ ${ }_{1} d E P(E)$. Remember the integral $1_{1} d x e^{x=d}=$ $\left(e^{x=k_{B} T}+1\right)=k_{B} T=\sin \left(k_{B} T=d\right)$ for $k_{B} T<d l_{1}^{1}$ o ne can see from the form ula ( $\left.(3)^{2} 6\right)$, that $E$ is $m$ ore sensitive to the action $S_{0}$ than to the tem perature $T$. In fact, the factor $\left(3 \mathrm{k}_{\mathrm{B}}\right.$ TS $\left.\mathrm{S}_{0}=\mathrm{h}\right)=\sin \left(3 \mathrm{k}_{\mathrm{B}}\right.$ TS $\left.\mathrm{S}_{0}=\mathrm{h}\right)$ is alm ost 1 (about 1:03 at room tem perature $\mathrm{T} \quad 300 \mathrm{~K}$ in the case I), and $E$ is approxim ated by $E \prime h=3 S o$.
B. Em ission area

At this point, we can discuss the assum ption on the em ission area in the ordinary F \{ N theory and the theory of H e et al. ${ }^{19}$, where the em ission areas are assum ed to be sm allenough and are regarded as planes. In our theory, the em ission area is not given by hand but is determ ined by the barrier penetration probability $D(\mathrm{~W} ; \mathrm{v})$ : It is the region where D ( W ; v ), which is the exponential factor in the $v$-integration in Eq. $\left.(\overline{3}, 17)_{1}\right)$, $p^{\text {is }}$ not zero and is estim ated as the region $\mathrm{v}<\sin \mathrm{u}_{0}=\overline{2 \mathrm{~S}_{0}=\mathrm{h}}$. This seem s at rst sight to $m$ ean that the em ission area is sm aller for a shanper em itter and to support the above assum ption. $T$ his is how ever not true. O ne should take the curvature of the area into account. $T$ he relevant $m$ easure is not the size itself but the solid angle of the area seen from the center of curvature, i.e., the angle 2 in Fig. 'I. The angle


FIG. 5: Em ission area $m$ easured by the angle 2 seen from the center of curvature.
is evaluated as

$$
\begin{equation*}
\left.\tan =\frac{\sin u_{0} \cos u_{0} \sinh \left(\sin u_{0}=p \bar{p} \overline{2 S_{0}=h}\right)}{1 \quad \cos u_{0} \cosh \left(\sin u_{0}=\right.} \overline{2 S_{0}=h}\right) \quad, \frac{p \overline{h=2 S_{0}}}{1 h=4 S_{0}} \tag{327}
\end{equation*}
$$

(for $s m$ all $u_{0}$ ), which show $s$ that, for a shanper em itter, the action $S_{0}$ is sm aller, and the angle 2 is larger. In this sense, the em ission area for a sharp em itter is not planar. Even in a conventional situation as the case $I_{\text {, }}$ the action is $S_{0}=h \quad 7: 6$ and the angle is $2 \quad 30$, which is not so sm all that the em ission area can be regarded as planar.

## C. Field em ission current I

It is also possible to execute the nalintegration ( $\overline{3} \overline{1} \overline{1} \overline{1})$ w ith the expression ( $\left(\overline{3} \overline{1} \mathbf{B}_{-1}\right)$ if tem perature $\mathrm{T}=0$. $\overline{\mathrm{T}}$ he em ission current I at zero tem perature is then

$$
\begin{align*}
& I=\frac{2 \mathrm{me}^{2} \mathrm{LR}^{2}}{3 \mathrm{~h}^{3}(\mathrm{~L}+\mathrm{R})} \frac{1}{\left(2 \mathrm{~S}_{0}=\mathrm{h}\right)^{4=3}} \\
& \quad\left(1=3 ; 2 \mathrm{~S}_{0}=\mathrm{h}\right) \quad\left(2 \mathrm{~S}_{0}=\mathrm{h}\right)^{2=3} \quad\left(\quad 1=3 ; 2 \mathrm{~S}_{0}=\mathrm{h}\right): \tag{3.28}
\end{align*}
$$

If the action $2 \mathrm{~S}_{0}=\mathrm{h}$ is large, how ever, a current form ula for nite tem perature is available: Integrating the energy distribution ( 3 2 $2 \overline{3}$ ), , one obtains

$$
\begin{equation*}
I=\frac{4 \mathrm{me}^{2} \mathrm{LR}^{2}}{9 \mathrm{~h}^{3}(\mathrm{~L}+\mathrm{R})} \frac{3 \mathrm{k}_{\mathrm{B}} \mathrm{TS}_{0}=\mathrm{h}}{\sin \left(3 \mathrm{k}_{\mathrm{B}} \mathrm{TS} S_{0}=\mathrm{h}\right)} \frac{1}{\left(2 S_{0}=h\right)^{3}} e^{2 \mathrm{~S}_{0}=\mathrm{h}}: \tag{3.29}
\end{equation*}
$$

$T$ hese current form ulae are again valid under the condition ( 3 2-5 $)^{-1}$ ). It has been known experim entally and the $\mathrm{F}\{\mathrm{N}$ theory has explained successfilly that eld em issiph, current does not depend on tem perature signi cantly 110 This is also the case with our hyperboloidal em itter m odel. A s already m entioned in the previous subsection, the factor $3 \mathrm{k}_{\mathrm{B}}$ TS $\mathrm{S}_{0}=\mathrm{h}$ found in Eq. ( 3 29 $\mathrm{I}_{1}$ ) is sm all and the tem perature correction to the current is only about $3 \%$ at room tem perature $\mathrm{T} \quad 300 \mathrm{~K}$. The tem perature dependence is hence negligible in the em ission current I.

Since the action $S_{0}$ is proportional to $\mathrm{V}_{0}{ }^{1}$ [see Eq. $(\overline{3} \cdot \overline{1} \overline{9})]$, the em ission current $(\overline{3} \overline{2} \overline{9}$ ) o ers the follow ing current \{voltage characteristics for the hypenboloidal em itter:

$$
\begin{align*}
& \frac{\mathrm{I}}{\mathrm{~V}_{0}^{3}} / \exp \frac{\mathrm{A}}{\mathrm{~V}_{0}} \text {; }  \tag{3.30a}\\
& A=\frac{4 L^{\mathrm{P}} \overline{2 \mathrm{~m}{ }^{3}}}{3 \mathrm{he}{ }_{0}} ; \quad 0=\frac{\cos u_{0}}{\sin ^{2} u_{0} \ln \cot \left(u_{0}=2\right)}: \tag{3.30b}
\end{align*}
$$

Rem ember the correspondingr,, plat
 try of em itter into account, we have obtained di erent
exponent of $\mathrm{V}_{0}$ on the left-hand side. This is one of the m ain results of th is article. The new exponent is a direct consequence of the G aussian integral over the variable v in Eq. (3.17), or roughly speaking, of the niteness of the em ission area, which com es from the niteness of the radius of curvature of the em itter. It is easily expected that the sim ilar situations arise for various shapes of em itter, where the integration over a nite em ission area yields som e exponent not necessarily the sam e as in the form ula ( 3 one. The geom etrical e ect, in general, $m$ anifests itself in the exponent ${ }^{15}$

It is interesting, on the other hand, that the exponential factor on the righthand side of Eq. (3 30 al the sam e as that of the conventional one. $T$ his, in som e sense, supports the validity of the planarm odel, since the current \{voltage characteristics are $m$ ainly dom inated by this exponential factor but the power on the left-hand side is relatively less im portant. It is not easy to observe the di erence in the exponent of $\mathrm{V}_{0}$ experim entally $\boldsymbol{y}^{\frac{3}{1}}$ and the conventionalF $\{\mathrm{N}$ theory w orks well fortunately.

O ur form ula ( $\left(30^{-2} 0^{\prime}\right)$ how ever does not coincide $w$ ith the one that He et al. concluded in Ref. perboloidal em itter $m$ odel, i.e., $I=V_{0}{ }^{2} / \exp \left(A=V_{0}\right.$ $B=V_{0}^{2}$ ). W hat is the reason for this discrepancy or what is the origin of the term $B=V_{0}^{2}$ ? The discrepancy seem $s$ at rst sight due to the fact that the im age chargee ect is neglected in our form ulation while H e et al. calculated it exactly. This is not the case, how ever. In general, the im age charge e ect becom es $m$ ore prom inent as the applied voltage increases, and the em ission current is accordingly enhanced. But such an e ect is not observed in their calculation. The additional $B=V_{0}^{2}$ term in the theory of He et al. com es not from the im age charge e ect but from the bias eld potential. In fact, if one retains the term of the order of $\left(u_{T} \ldots L_{b}\right) \operatorname{cotu}_{0}{ }^{\prime}(L=R)\left(W=V_{0} \quad 0\right)$ in the action integral ( $(\overline{3} \mathbf{1} \overline{1} \overline{1})$ ), which we have neglected there, such a correction appears:

$$
\begin{equation*}
S_{0}(W)=\frac{2 L^{p} \overline{2 m(W)^{3}}}{3 e V_{0} 0} 1+\frac{L}{R} \frac{(W)}{e_{0} 0}+ \tag{3.31}
\end{equation*}
$$

where is a positive constant of the order of $1^{-1} \mathbf{1}^{-1} \mathrm{~T}$. his correction comes in when the em itter is so sharp that the linear approxim ation of the bias eld potentialV (u) in Eq. ( $(\overline{3} . \overline{1}-1)$ is not valid. N pte the $R$-dependence of ( $\left.u_{T} \quad u_{b}\right) \cot u_{0}, 3 S_{0}(\mathbb{W})=2 R \overline{2 m(W)}$. It should be noted, how ever, that em itters $w$ th very shanp radii do not $t$ in wellw ith our formulation as $m$ entioned in the second paragraph of this section.
IV. ESTIM ATION OF EXPERIMENTS

In our form ulae, w e have the param eter $u_{0}$, which characterizes the shanpness of the hyperboloidal em itter and is not contained in the ordinary $F\{N$ theory based on
the planar em itter m odel. Finally, let us try to analyze actual experim ents by m aking use of this feature. The experim ental data to be tted in the follow ing were obtained for tungsten em itters in the experim ents whose details are presented in $R$ ef.' $'$. In those experim ents, the param eter $L$ is about $L \quad 5 \mathrm{~cm}$.

## A. Current\{voltage characteristics

Experim ental data of current\{voltage characteristics
 those for norm al clean em itters but also those for nanotip em itters' which are fabricated on the apexes of the form ers are plotted in the same gures. The verticalax is $\mathrm{I}=\mathrm{V}_{0}^{3}$ in F ig. ' G is di erent from that of the ordinary $\mathrm{F}\{$ N plot, $I=V_{0}^{2}$, and each series of data is well tted by a straight line, i.e., by the form ula ( $\left.{ }^{-}=10{ }^{-1}\right)$.

A s already $m$ entioned in the previous section, ttings of the data w th the conventionalF $\{\mathrm{N}$ form ula also work well sim ilarly to the ones w th our formula shown in Fig. ter $u_{0}$, which characterizes the sharpness of the em itter, while the conventional one does not. W e can hence es-


FIG.6: Experim ental data of current\{voltage characteristics for four di erent pairs (A (D) ofem itters: D ashed lines are for norm al clean em itters, an,d solid lines for nanotips fabricated on top of the clean ones' ${ }^{\prime} \mathbf{I}^{\prime}$ E ach series of data is tted by the form ula 3.201 .

TABLE II: R adii of curvature of the em itters estim ated by the ttings in Fig. 6 w ith $=4: 4 \mathrm{eV}$ and $\mathrm{L}=5 \mathrm{~cm}$.


F IG . 7: (a) R adius of curvature of a clean em itter and (b) effective radius of curvature of a nanotip em itter.
tim ate the radii of curvature $R$ of the em ilters by the ttings, which are listed in Table ${ }^{T I T}$. It should be noted there that the radii of curvature for the nanotips are not exactly those of the tips of the em itters: They are just the radii of curvature of ective clean em itters which em it the sam e currents as the actualem itters w ith nanotips ( F ig. $\mathrm{C}_{1} \overline{7}_{1}$ ) . O ne can see from this estim ation, how ever, that a nanotip fabricated on top of a clean em itter has such an e ect that it reduces the radius of curvature of the em itter to the extent of a half of the original clean one.

## B . Energy distribution

E nergy distributions for norm al clean em itters are also tted well by the form ula ( $(\overline{3},-\overline{8})$ and $(\overline{3}-23)$ as show $n$ in Fig. 1 . The param eter $u_{0}$, i.e., the radius of curvature $R$ of em itter, is again obtained by the tting. I he radius of curvature of the clean em itter A in Fig. 'i' $\overline{6}$, which is estim ated w th the data for di erent applied voltages $\mathrm{V}_{0}$, is presented in Table III. A though the radius of curvature $R$ should be independent of the applied voltage $V_{0}$, of course, the estim ated value decreases slightly $w$ ith $V_{0}$. This is due to the im age charge e ect. This e ect is neglected in our form ulation, and the enhance-

TABLE III: T he radius of curvature $R$ of the clean em itter A in $F$ ig. ${ }^{1} G$ Gestim ated by tting energy distributions for di erent applied voltages $V_{0} w$ ith the form ula (323). T he param eters are $\mathrm{xed}=4: 4 \mathrm{eV}, \mathrm{T}=300 \mathrm{~K}$, and $\mathrm{L}=5 \mathrm{~cm}$.

| $\mathrm{V}_{0}(\mathrm{kV})$ | 3.8 | 4.0 | 4.2 | 4.4 |
| :--- | :--- | :--- | :--- | :--- |
| $\mathrm{R}(\mathrm{nm})$ | 114 | 113 | 111 | 95 |



FIG.8: Experim ental data (dots) of the energy distribution for the clean em itter A in $F$ ig. ${ }^{\prime} 6$ by the form ula (3 23) in the log-linear plot (b) w th the param eters $\mathrm{E}_{\mathrm{F}}={ }^{--}=4: 4 \mathrm{eV}$ and $\mathrm{T}=300 \mathrm{~K}$ xed. The linear one (a) is draw $n$ w ith the sam e param eters as in (b).
$m$ ent ofthe em ission current due to it is renorm alized into the param eter $u_{0}$, i.e., into the shanpness of the em itter. $T$ he enhancem ent is a slow ly increasing function of $V_{0}$ as already $m$ entioned in the previous section, and the estim ated radius of curvature of the em itter accordingly decreases w ith $\mathrm{V}_{0}$. O ne hence has to be careful about the fact that the im age charge e ect is included in the param eter $u_{0}$.

## V. CONCLUSION

In this article, we have derived eld em ission form ulae from a hyperbolbidal_em itter_m odel, i.e., current $\{$
 ergy distribution of em 计ted electrons ( $\left.(3.18)^{\prime}\right)$ and $\left(\overline{3} 2 \overline{2} 3^{\prime}\right)$, which are valid under the condition (325). Re ecting the geom etry of the em itter, the traditional $F$ \{ $N$ formulae, which are derived based on the planar em itter m odel, are m odi ed. The current\{voltage characteristics in the $F\left\{N\right.$ theory, $I=V^{2} / \exp (A=V)$, is replaced $w$ ith $I=V^{3} / \exp (A=V)$, for exam ple. The geom etrical e ect $m$ anifests itself in the exponent of $V_{0}$ on the left-hand side.

W e have also addressed and reconsidered the assum ption of the planar em itter in the $\mathrm{F}\{\mathrm{N}$ theory. An esti$m$ ation of the spread of em ission area based on the formula ( 3 271) shows that the area cannot be regarded as planar even for a conventionalem itter.

Furthem ore, our analytical calculation has revealed the backgrounds of the conclusions drawn by He et al, ${ }^{19}$ which are based on a num erical calculation: The origin of the correction term in their current \{voltage characteristics has been clari ed, and the dependence of the w idth of energy distribution on radius of curvature of em itter has been explained. The concise form ula ( $\overline{3} 2 \overline{2} \overline{1})$ for the w idth of energy distribution m ight be usefiul in practical experim ents.

A nd nally, we have atterp pted to analyze experim entaldata ofnanotip em itters ${ }^{16}$ by $m$ aking use ofthe param eter $u_{0}, w h i c h ~ c h a r a c t e r i z e s ~ t h e ~ s h a p p e s s ~ o f ~ t h e ~ e m ~ i t t e r s, ~$ and clari ed an e ect of a nanotip fabricated on top of a norm alclean em itter: T he ective radius of curvature
of the em itter is considerably reduced.
O ne should note, how ever, that our form ulae do not explain the characteristics peculiar to nanotip em itters exactly. A ctually, energy distributions for nanotip em itters ${ }^{151}, 1 / 1$ for example, cannot be tted by our formula $(\overline{3} \cdot \overline{1} \overline{1})$ and $(\overline{3} 2 \overline{2})$. O ne of the reasons for this is that electrons cannot be treated as localized ob jects in nanotips, whose radii of curvature are of the order of 1 nm . For a rigorous description of eld em ission from today:'s, nanoscale tips, a fully quantum treatm ent is required $\mathbf{I n}^{1011}$

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 A 119, 173 (1928).
2 L. N ordheim , Proc. R oy. Soc. (London) A 121, 626 (1928).
${ }^{3}$ R .H . G ood, Jr. and E.W .M uller, in H andbuch der P hysik, edited by S.F lugge (Springer-V erlag, B erlin, 1956), vol.21, pp.176\{231.
${ }^{4}$ R.D. Young, Phys. Rev.113, 110 (1959).
${ }^{5}$ V .T . B inh, S.T . P urcell, N . G arcia, and J.D oglioni, P hys. Rev. Lett. 69, 2527 (1992); V. T. Binh and V. Sem et, U ltram icroscopy 73, 107 (1998).
${ }^{6}$ K . N agaoka, H . Fu $\mathfrak{j i}$ i, K .M atsuda, M . K om aki, Y .M urata, C.O shim a, and T.Sakurai, A ppl. Surf. Sci. 182, 12 (2001).
${ }^{7}$ A. G.R inzler, J. H . H afner, P. Nikolaev, L. Lou, S. G . K im , D. Tom anek, P . N ordlander, D.T.C olbert, and R .E. Sm alley, Science 269, 1550 (1995); Y . Saito, K . H ata, and T.M urata, Jpn. J.A ppl. Phys. 39, L271 (2000).
${ }^{8}$ J. He, P. H. Cutler, N.M.M iskovsky, T.E. Feuchtw ang, T.E.Sullivan, and M . C hung, Surf. Sci. 246,348 (1991).

9 J. He, P. H. C utler, and N.M.M iskovsky, A ppl. Phys. Lett. 59, 1644 (1991).
${ }^{10}$ N. D. Lang, A. Y acoby, and Y. Im ry, P hys. R ev. Lett. 63, 1499 (1989).
${ }^{11}$ Y. G ohda and S.W atanabe, P hys. R ev. Lett. 87, 177601 (2001); Surf. Sci. 516, 265 (2002).

12 L. I. Schi , Q uantum $M$ echanics ( $M$ OG raw $H$ ill, Inc., Singapore, 1968), 3rd ed.
${ }^{13}$ The distance dr between two points (u;v;') and (u + $\left.d u ; v+d v ;^{\prime}+d^{\prime}\right)$ is given by $d r^{2}=a^{2}\left(\sin ^{2} u \cosh ^{2} v+\right.$ $\left.\cos ^{2} u \sinh ^{2} v\right)\left(d u^{2}+d v^{2}\right)+a^{2} \sin ^{2} u \sinh ^{2} v d^{\prime 2}$.
14 I. S. G radshteyn and I. M . Ryzhik, Table of Integrals, Series, and P roducts, edited by A. Je rey and D. Zw illinger (A cadem ic P ress, O rlando, 2000), 6th ed.
15 O ne $m$ ay consider that our form ula ( 3.301 ) should coincide w th the conventionalF $\{\mathrm{N}$ formula in the lim it $\mathrm{R}!1$. It is not the case, how ever, because the expansion of the action $S(W, V)$ in Eq. (3.13) is valid only when the em ission area is nite, but the area is in nite forconventionalplanar em itter $m$ odel. The new form ula ( $3.30_{1}^{\prime}$ ), which is derived w ith this expansion, therefore, cannot be reduced to the conventional one even if the radius of curvature $R$ is taken to in nity.
${ }^{16}$ It is easy to understand the sign of $B=V_{0}^{2}$, i.e., positivity of in Eq. $\left(3 \bar{I}_{1}\right)$, since $O\left(\left(u_{T} \quad u_{0}\right) \cot u_{0}\right)$ correction to the bias eld pōtential $U(u)$ is alw ays positive and gives rise to a positive correction to the action $S_{0}(W)$.

